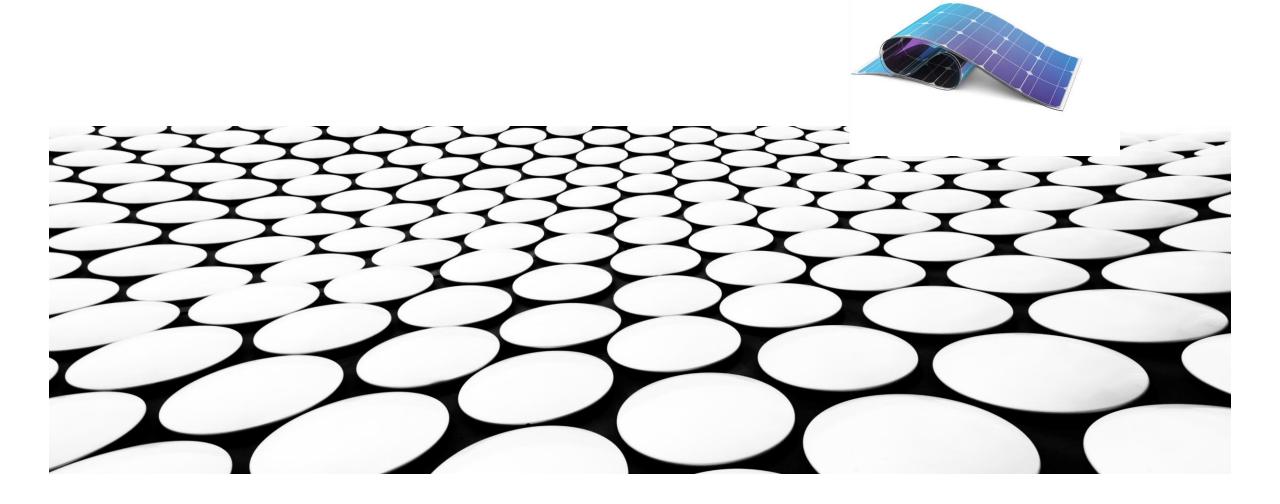
## WELCOME TO MY PRESENTATION

Presentation Topic: Thin Film

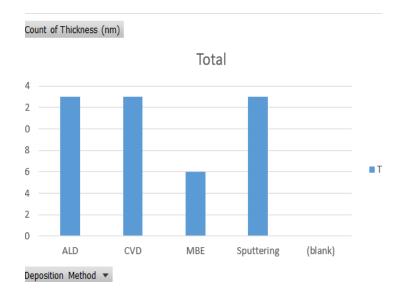
### **THIN FILM**



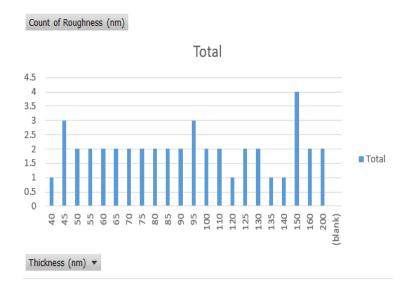
### **TABLE OF CONTENT**

- Count of thickness.
- Deposition method .
- Thickness
- Roughness.
- Refractive index.
- Temperature.
- Optical bandgap(ev)

How does deposition method affect the thin thickness?
 At first deposition increase with thickness then it decrease suddenly then it increase.



- What is the reationship between film thickness and roughness?
- I see that the relationship between film thickness and roughness firstly increase the it decrease and constant at 2 thin it increase and decrease it 2 and constant it and increase gradually and it has constant at 2.



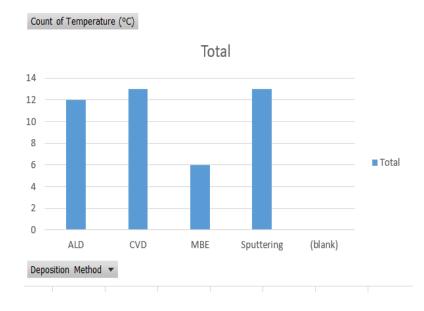
Which deposition method results in the refractive index?

Chemical vapor deposition CVD.



How does the deposition method affect with temperature?

The deposition rate increases with temperature from 300 to 400 degree celcius and then starts to decrease above 400 degree celcius.



Which thin film have the highest optical band gap?
 Tio2 Have the highest optical band gap.

# Count of Optical Bandgap (eV) Total Total Also a Cu20 Ga203 Ga203 Ga203 Ga203 Also a Cu20 Si304 Also a Cu20 Si304 Also a Cu20 Si304 Also a Cu20 Si304 Also a Cu20 Also a Cu20 Si304 Also a Cu20 Also a Cu20

# **THANK YOU**